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NIPHOS[®] 966

NICKEL-PHOSPHORUS ELECTROLYTE



Alternative to Electroless Nickel

With NIPHOS[®] nickel-phosphorus alloy layers with high phosphorus content can be plated electrolytically in barrel-, rack- or reel-to-reel lines. Compared to electroless nickel layers containing a high phosphorus content, the electrolytic nickel-phosphorus layers are amorphous, diamagnetic and abrasion and corrosion resistant. The layers can be applied as intermediate layer (prior to e.g. tin, chromium or gold) or as final layer. In comparison to electroless nickel, electrolytic nickel-phosphorus electrolytes are operated at low temperatures.

Nickel-phosphorus electrolytes can be operated with soluble anodes (nickel), insoluble anodes (platinum plated or MMO) or a combination of both. The lifetime is almost unlimited and corresponds to the one of bright nickel electrolytes. NIPHOS[®] is insensible to contaminations with metallic particles. In contrary to electroless nickel it does not tend to random plating. Also the electrolytes are free from halides and contain, besides nickel, no other heavy metals such as lead or cadmium.



Advantages

- Cost advantage compared to electroless nickel up to 50%
- High phosphorus content of P > 11 %
- Simple electrolyte maintenance at electrolyte temperatures of 60°C
- Long lifetime of the electrolyte
- Does not contain any halides, sulphur or heavy metals such as lead or cadmium
- Weldable and bondable surface layer
- For rack-, barrel- or reel-to-reel operation
- High hardness (up to 1,200 HV after heat treatment)
- Very good abrasion and corrosion resistance
- Suitable as final or intermediate layer

Applications

- Diamagnetic coatings of RF connectors
- Intermediate layer prior to gold-plating of connectors
- Electroforming, e.g. of matrices
- Hydraulic, e.g. piston rods

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TECHNICAL SPECIFICATIONS

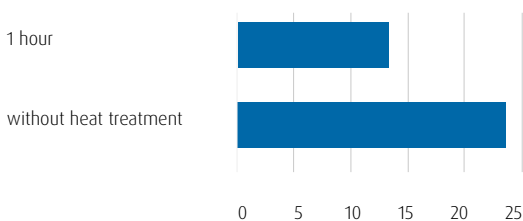
Electrolyte characteristics	
Electrolyte type	Acidic
Contents	80 (60 - 90) g/l Ni 25 (22 - 28) g/l P
pH value	2.6 (2.5 - 2.7)
Operating temperature	60 (55 - 75) °C
Current density	
Rack	4 (3 - 5) A/dm ²
Barrel	1.5 (1 - 2) A/dm ²
Plating speed	
Rack operation at 4 A/dm ²	0.4 µm/min
Barrel operation at 1.5 A/dm ²	0.15 µm/min
Anode material	Nickel (type S) or Pt-Ti, MMO (type PLATINODE® 177)

NIPHOS® Nickel-Phosphorus Electrolytes

- NIPHOS® 966 for rack and barrel operation
- NIPHOS® 967 for rack and barrel operation

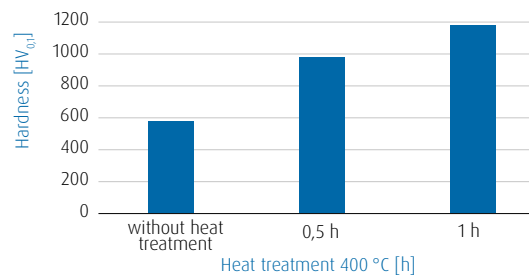
Influence of the heat treatment on the abrasion resistance; Taber Abraser, CS-10; heat treatment temperature: 400 °C

Abrasion [mg/1.000 revolutions]



Coating characteristics	
Coating	Nickel-phosphorus
Alloy composition	87 - 89 wt.% Ni 11 - 13 wt.% P
Colour of deposit	Steel-grey
Brightness	Bright
Hardness of deposit HV 0.015 (Vickers) approx. values	550 - 600 HV
Density	Appr. 7.8 g/cm ³

Impact of the Heat Treatment at 400 °C on the Hardness



Corrosion Resistance of NIPHOS®

Neutral salt spray test (DIN EN ISO 9227-NSS)

NIPHOS® 20 µm > 336 h

CASS test (DIN EN ISO 9227-CASS)

NIPHOS® 20 µm > 150 h

Corrodokote test (DIN EN ISO 50958)

NIPHOS® 20 µm 7 Zyklen

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Electroplating

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